

SHEET 1 OF 1

INFC	CIT	ATION DISCLO TATION IN AN PPLICATION	ATTY. DOCKET NO. 057810-0088		SERIAL NO. 10/790,759				
			APPLICANT EIJI MARUYAMA						
(PTO-1449)				FILING DATE March 03, 2004					
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.